

10/565104

IAP20 Rec'd PCT/PTO 19 JAN 2006

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :
Hiroki MAEDA et al. : **Mail Stop: PCT**
Serial No. NEW : Attorney Docket No. 2006_0043A
Filed January 19, 2006 :

PHOTOSENSITIVE RESIN
COMPOSITION AND METHOD OF
FORMING A PATTERN USING
THE COMPOSITION
[Corresponding to PCT/JP2004/018759
Filed December 15, 2004]

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows:

ATTACHMENT F

IAP20 Rec'd FGT/PTO 19 JAN 2006

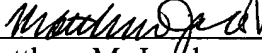
3. ☐ Consideration of the following list of additional information (including any copending or abandoned U.S. application, prior uses and/or sales, etc.) is requested.
4. For each non-English language reference listed on the attached form PTO-1449, reference is made to:
- a. ☐ a full or partial English language translation submitted herewith,
 - b. ☒ a foreign patent office (International) search report (in the English language) submitted herewith (Attachment G),
 - c. ☒ the concise explanation contained in the specification of the present application at pages 2 and 3,
 - d. ☒ the concise explanation set forth in the attached English language abstract,
 - e. ☒ the concise explanation set forth below or on a separate sheet attached to the reference:

-JP 7-78628 B2 corresponds to U.S. 4,882,245
-JP 2-279718 corresponds to U.S. 5,026,624
-EP 0 927 726 A1 corresponds to JP 10-147608
5. ☐ A foreign patent office search report citing one or more of the references is enclosed.

Respectfully submitted,

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

Hiroki MAEDA et al.

By 
Matthew M. Jacob
Registration No. 25,154
Attorney for Applicants

MJ/kes
Washington, D.C. 20006-1021
Telephone (202) 721-8200
Facsimile (202) 721-8250
January 19, 2006